

ORIGINALLY FILED

17X1036

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s):

Zhijian Lu et al.

Serial No.:

09/966,923

Filed:

September 28, 2001

Entitled:

Method For Ending Point Detection During

Etching Process

Group Art Unit:

TBD

Examiner:

TBD

Docket No.:

01 P 14628 US

Batch No.:

TBD

LETTER TO OFFICIAL DRAFTSMAN

Attention: Drawing Processing Branch Assistant Commissioner for Patents Washington, D.C. 20231

Sir:

Pursuant to M.P.E.P. Section 608.02, enclosed please find four (4) sheets of formal drawings in the referenced case. These are formal versions of the informal drawings filed with the application.

If there are any informalities with these drawings, Applicant requests issuance of a Form PTO-948 identifying the informalities noted by the Official Draftsman.

Date: February 21, 2002

Infineon Technologies North America Corp. c/o Siemens Corporation
Intellectual Property Department
186 Wood Avenue South
Iselin, NJ 08830
(732) 321-3015
SCB/vl

Respectfully submitted,

Stanton C. Braden Reg. No. 32,556

RECEIVEL TO 1700

CERTIFICATE OF MAILING PURSUANT TO 37 CFR § 1.8

I hereby certify that this correspondence is being deposited on or before the date, <u>February 21, 2002</u> with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to: Assistant Commissioner for Patents, Washington, D.C. 20231

Date of Signature: February 21, 2002

Pamela J. Gewirt